

Supporting Information for
**Self-assembly of carbon nanotube polyhedrons
inside microchannels**

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Figure S1. Schematic diagram of the experimental set-up.



Figure S2. SEM image of CNT polyhedrons formed on the upper plate of the SiO₂/Au sandwich.

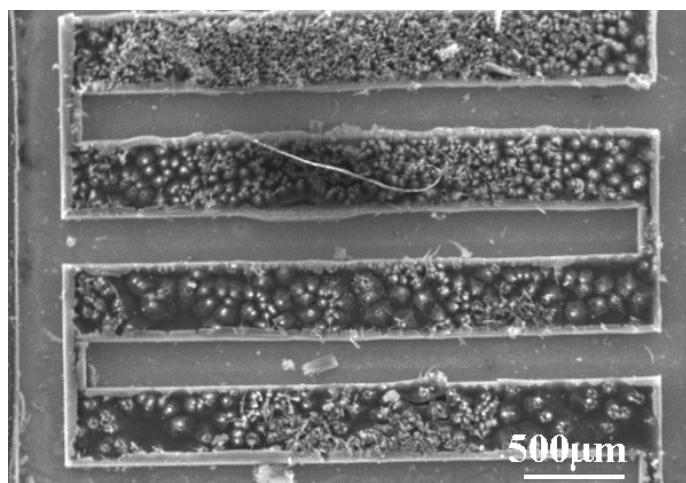


Figure S3. SEM images of CNT polyhedrons inside different channels of (a) #1 (b) # 6 of 8 along the gas flow path.

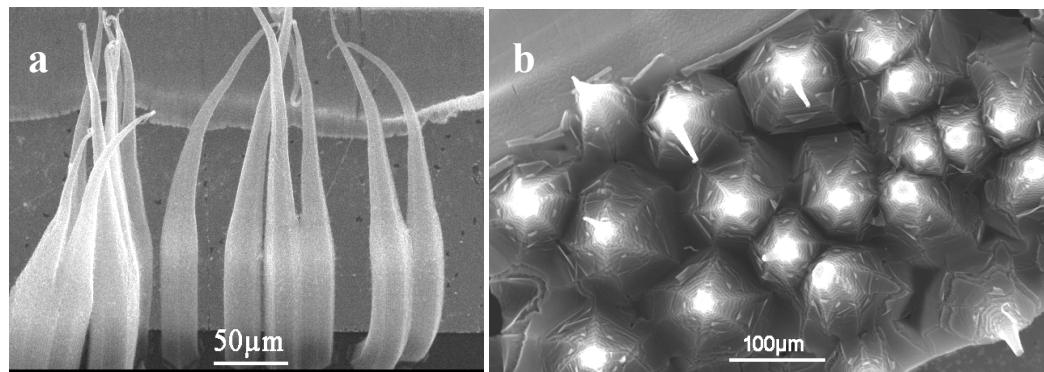


Figure S4. Schematic illustration of a base growth process of CNT polyhedron.

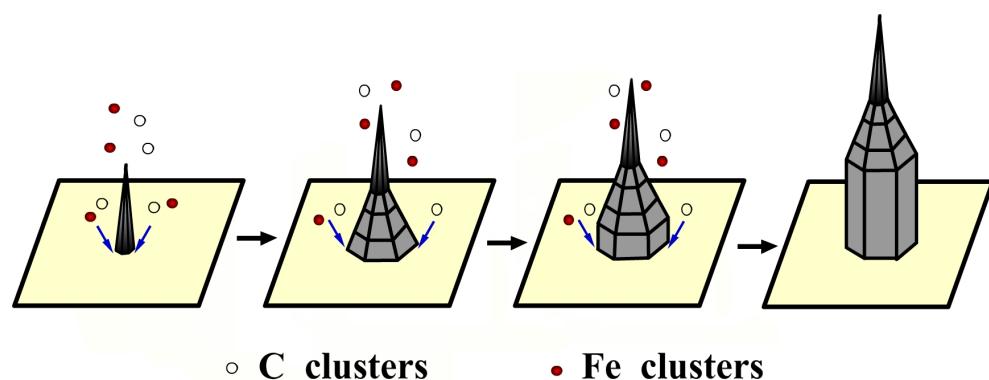


Figure S5. SEM images of different parts of a typical CNT-based polyhedron: (a) flattened tip, probably resulting from the contact with the upper plate covering the microchannel assembly, (b) serpentine tail buckled due to the contact with the upper plate, (c) polygonal dome, (d) column of well-aligned CNTs.

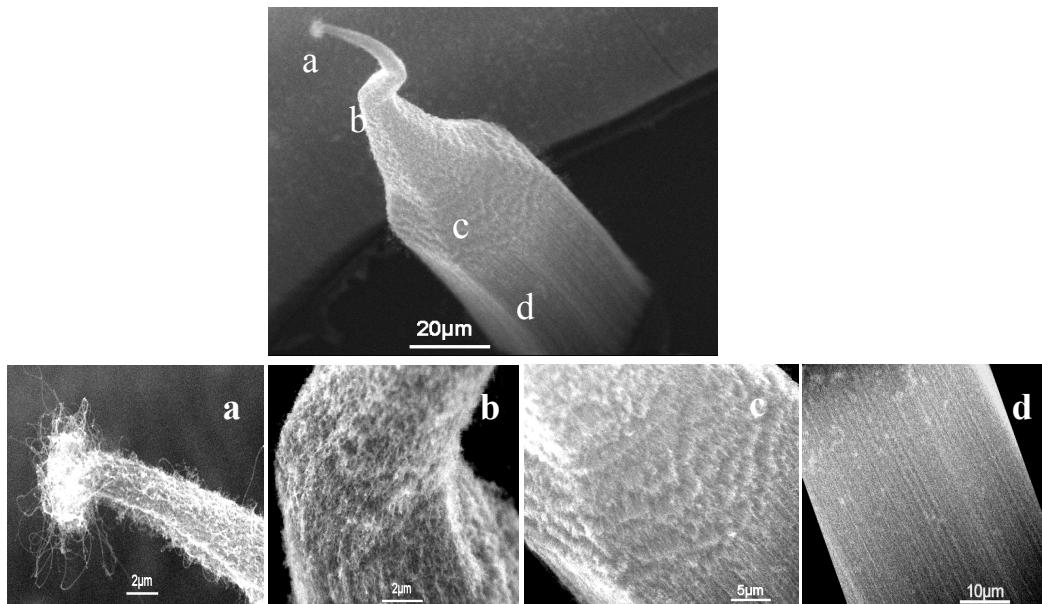


Figure S6. The wettability is evaluated by measuring the contact angle (CA) of water of CNT patterned surfaces on the substrate (Contact Angle System, Dataphysics OCA20). Shapes of water droplets on the surface of the substrate with (a) CNT polyhedrons on an open substrate and (b) CNT forest on the capped substrate are shown. The CA was about 162° and 144° , respectively, showing the CNT-patterned polyhedral structures are superhydrophobic.

